

In re application of

Confirmation No. 9635

Satoshi MAEMORI et al.

Docket No. 2001 1300A

Serial No. 09/955,111

Group Art Unit 1752

Filed September 19, 2001

Examiner S. LEE

POSITIVE-WORKING PHOTORESIST COMPOSITION AND PHOTOSENSITIVE MATERIAL USING SAME

AMENDMENT

THE COMMISSIONER IS AUTHORIZED ACCOUNT NO. 23-0975

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In response to the Official Action dated December 19, 2002, the time for responding thereto being extended for three months in accordance with a Petition for Extension of Time submitted herewith, please amend the present application as follows: